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(71) Applicant: PICOSUN OY [FI/FI]; Tietotie 3, 02150 Espoo (FI).

(72) Inventor: KALLIOMÄKI, Jesse; Kalastajanpolku 1 D 67, 00560 Helsinki (FI).

(74) Agent: HEINONEN & CO, ATTORNEYS-AT-LAW, LTD; Fabianinkatu 29 B, 00100 Helsinki (FI).

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(54) Title: PLASMA RESISTANT COATING, RELATED PRODUCTION METHOD AND USES

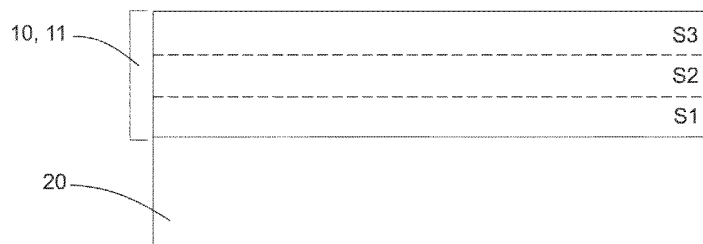


Figure 1

(57) Abstract: A method of producing coated substrates resistant to plasma corrosion and a related coating are provided. The method comprises depositing, over at least a portion of a substrate, an yttrium-containing plasma resistant coating through a process of chemical deposition in vapour phase, preferably, through Atomic Layer Deposition (ALD). In some configurations, the plasma resistant coating is formed with a mixture film composed of a mixture of an aluminium oxide compound and an yttrium oxide compound, for example. In some instances, a multilayer laminate structure comprising said mixture films alternating with deposition films composed of a metal fluoride compound is formed. A coated component for use in a plasma processing apparatus and a method for improving resistance of a substrate to plasma corrosion are further provided.



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